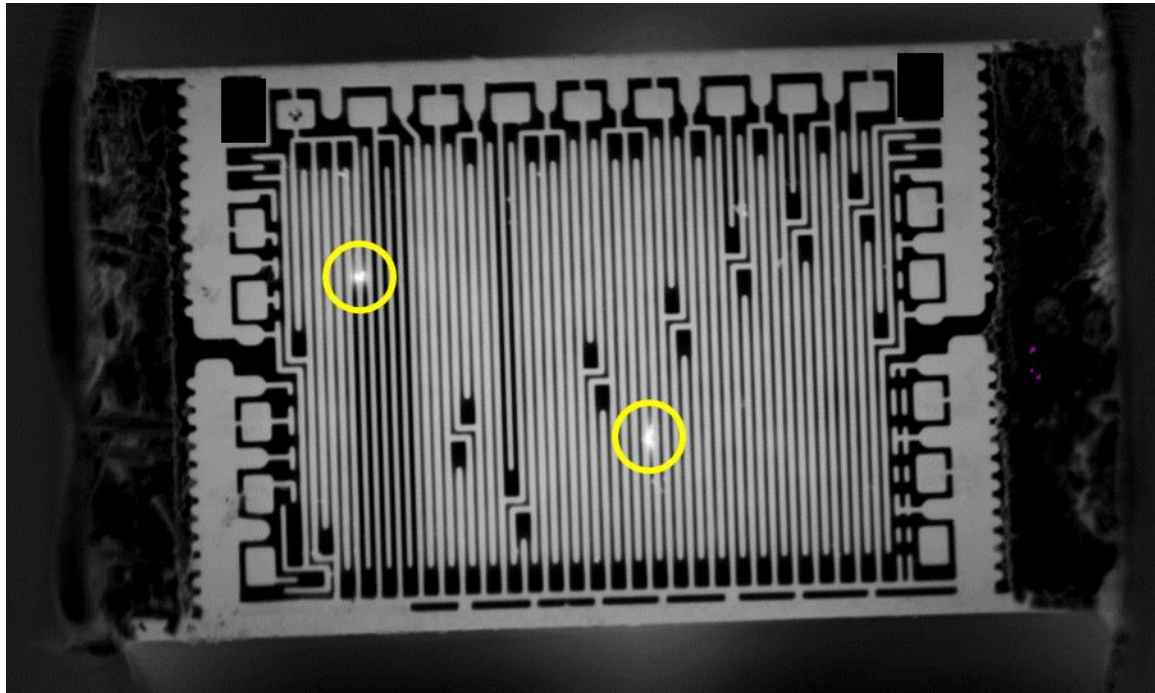




A Screening Method Using Pulsed-Power Combined with Infrared Imaging to Detect Pattern Defects in Bulk Metal Foil or Thin Film Resistors



Jay Brusse

ASRC AS&D at NASA Goddard Space Flight Center

Lyudmyla Panashchenko

NASA Goddard Space Flight Center



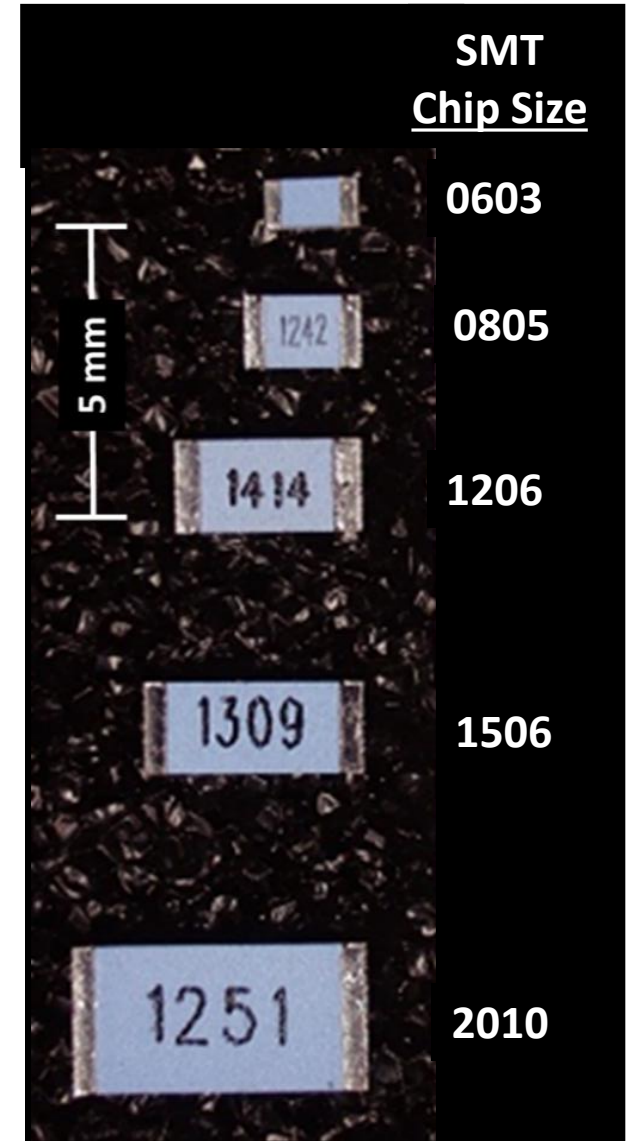
Acronyms & Abbreviations

Al-N	Aluminum Nitride
DPA	Destructive Physical Analysis
FA	Failure Analysis
InSb	Indium Antimonide
NASA	National Aeronautics and Space Administration
NEPP	NASA Electronic Parts & Packaging (NEPP) Program
NiCr	Nichrome
ppm	Parts Per Million
PWB	Printed Wiring Board
SEM	Scanning Electron Microscope
SMT	Surface Mount Technology
STOL	Short Time Over Load
TCR	Temperature Coefficient of Resistance



Foil Resistors Have Many Favorable Attributes

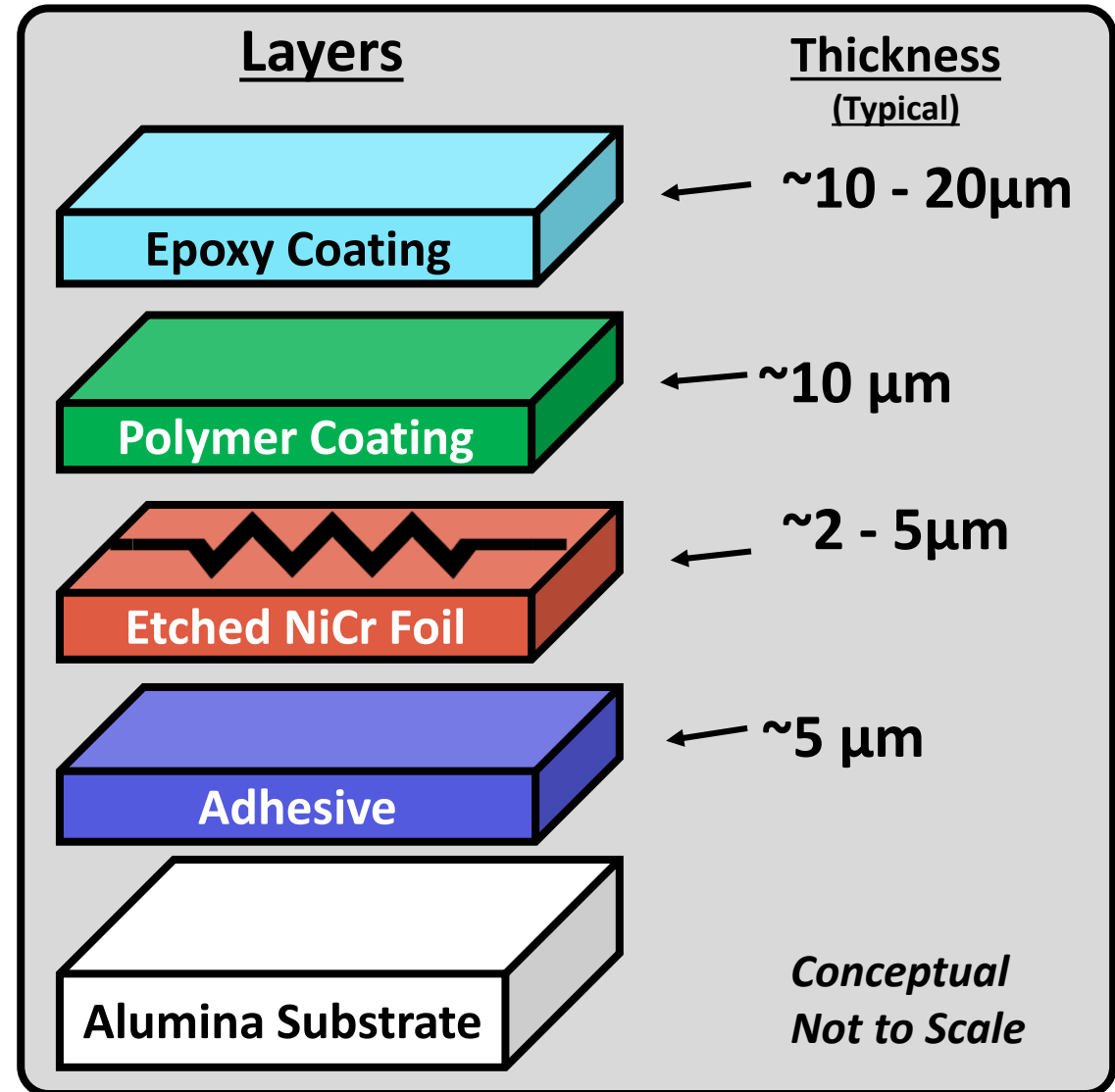
Attribute	
Package Configurations	Surface Mount Technology (SMT); Through Hole
Resistance Values	Custom Values; 5Ω to 125kΩ (standard SMT)
Resistance Tolerance	± 0.01% (± 100 ppm)
Temperature Coefficient of Resistance (TCR)	< ± 1 ppm/°C from -55°C to +125°C
Load Life Stability	± 0.03% (± 300ppm) after 2k hour life test @ 1x rated power @ 70°C



Basic Construction of a SMT Foil Resistor



- Resistor element is made from foil sheets of NiCr-based alloys
- Resistor gridline patterns are created by photolithography and electrochemical etching
- Resistor foil is adhesively-bonded to an alumina substrate
- Precise resistance values achieved by laser or mechanical cutting of combinations of “trim tabs” connected in parallel with resistor pattern segments of different values
- Various resistor termination options exist
- Polymeric and epoxy coatings protect the resistor element



Foil Resistor Gridline Patterns

$$R = \frac{\rho * L}{A}$$

R = Resistance (Ω)
 ρ = Resistivity of Foil
L = Length of Resistor Element
A = Cross Sectional Area of Gridline
(i.e., thickness * width)

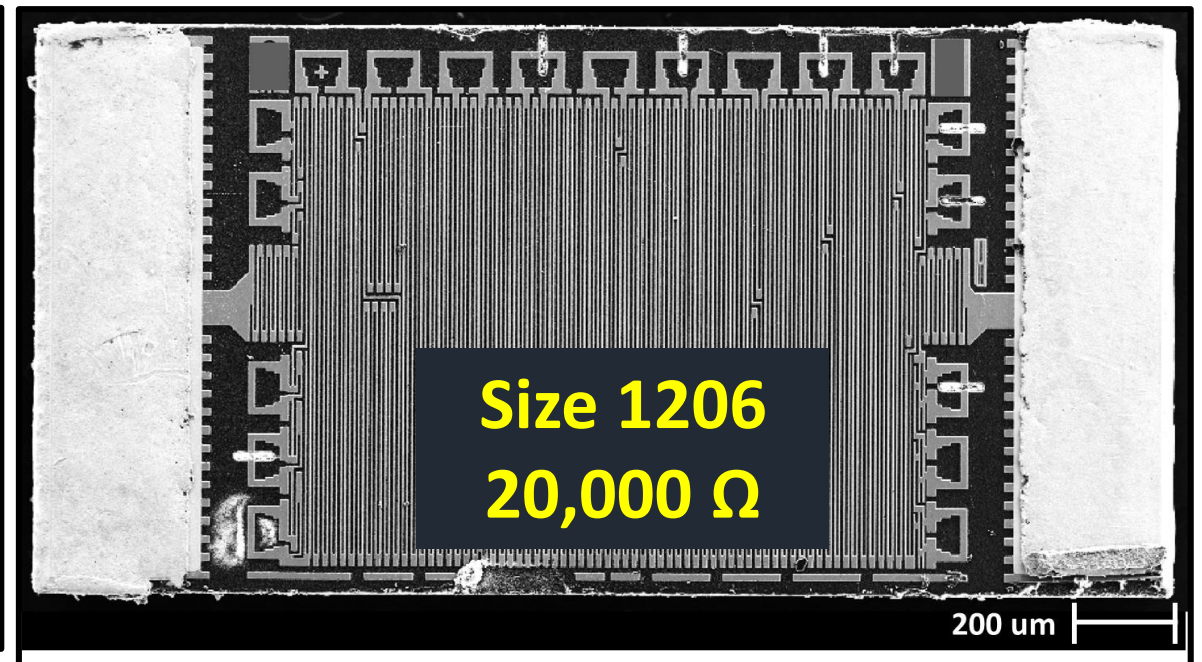
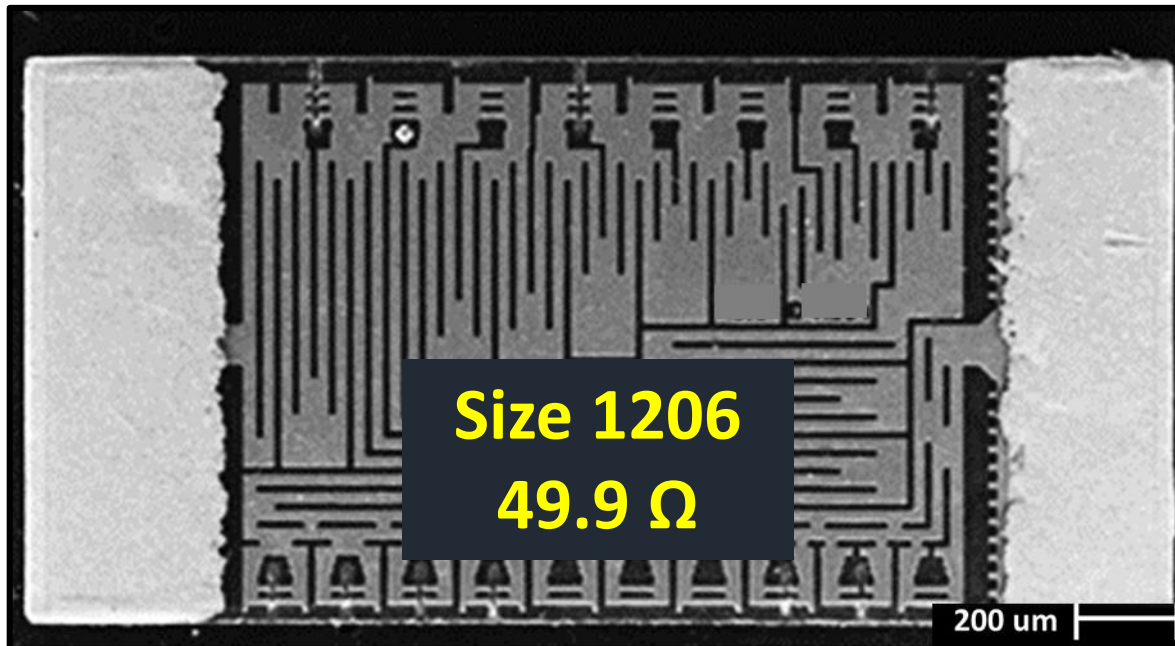


Low Resistance Values

1. Wider Foil Gridlines (e.g., $\sim > 10 \mu\text{m}$)
2. Thicker Foil (e.g., $\sim 5 \mu\text{m}$)
3. Shorter Path Lengths

High Resistance Values

1. Narrower Foil Gridlines (e.g., $\sim < 10 \mu\text{m}$)
2. Thinner Foil (e.g., $\sim 2 \mu\text{m}$)
3. Longer Path Lengths



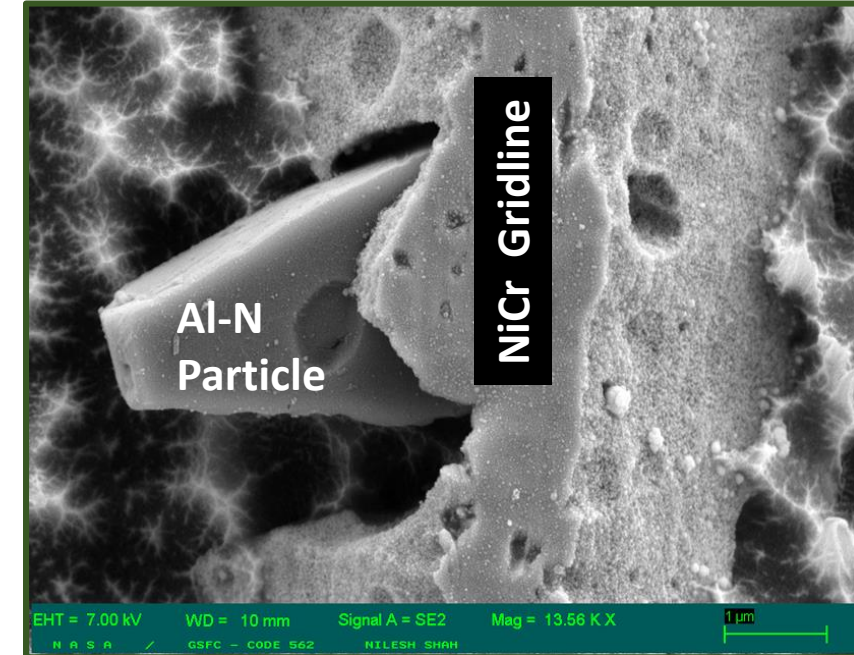
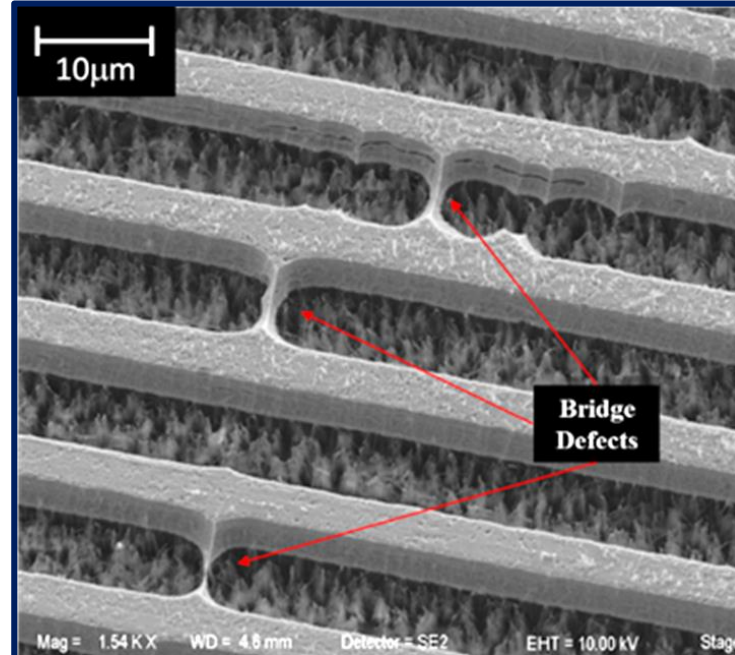
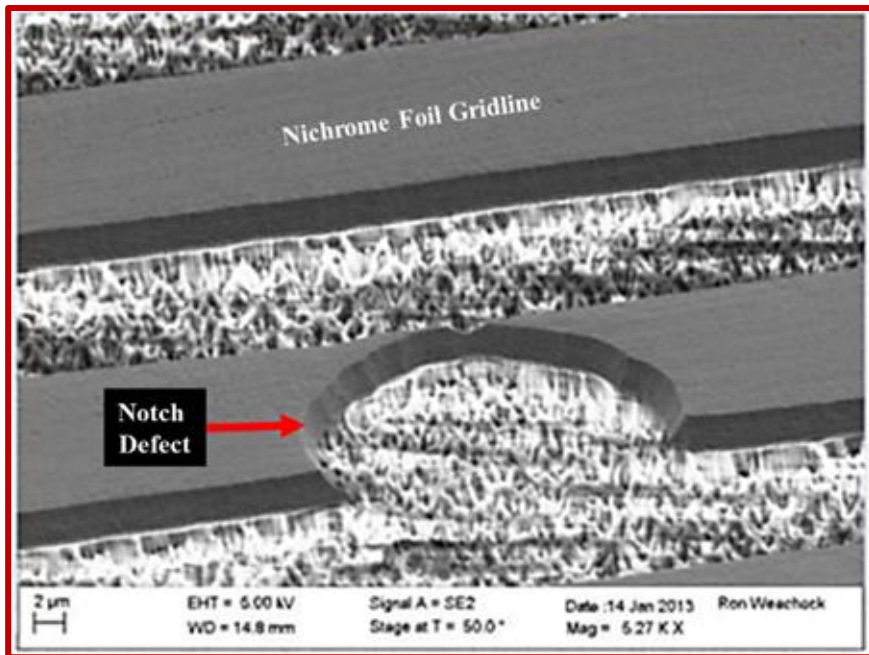
Foil Resistors Are Sometimes Produced with **Localized Constriction Defects** in the Gridline Pattern



Notches

Bridges

Embedded Particles



1. Constriction defects contribute directly to the final resistance value (e.g., bridges provide parallel resistor pathway).
2. Constriction defects are at risk of breaking due to thermomechanical fatigue fracture especially during power cycling
 1. Constrictions carry higher current density and develop localized 'hot spots' due to Joule heating
 2. Hot spots produce locally greater expansion of the NiCr foil
3. ***If a constriction defect fractures, then a positive resistance shift, including open circuit, will occur.***

Standard Screening Tests are **Not 100% Effective** at Detecting Constriction Defects

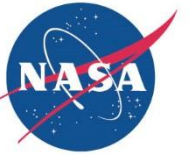


***Despite Performing These Screening Tests,
Resistors with Significant Constriction Defects are Still Occasionally Received***

Test Method	Test Conditions	Rejection Criteria
Pre-Encapsulation Optical Microscopy	30x to 60x Magnification	Notches > 75% nominal line width Bridges < 10% smallest line width
Short Time Overload (STOL)	6.25x Rated Power For 5 Seconds	$\Delta R > 0.02\%$
Power Conditioning	1x to 1.5x Rated Power @ Max Operating Temp For 100 Hours	$\Delta R > 0.03\%$

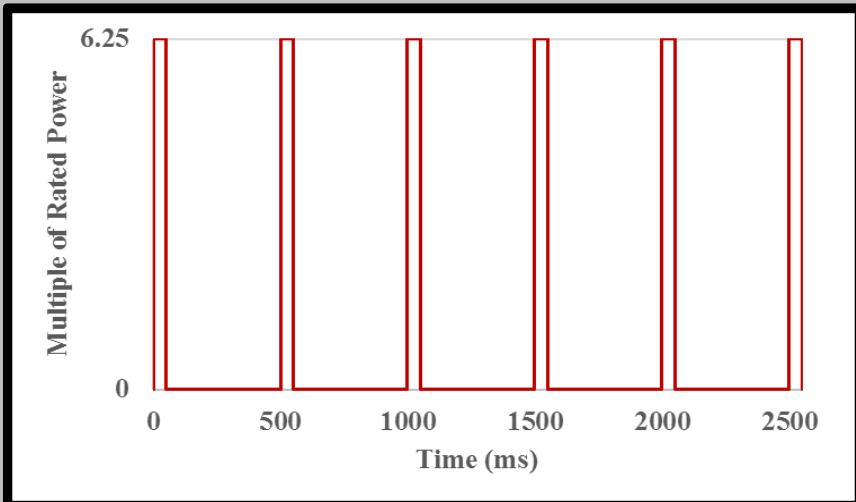
Hot Spots! A New Screening Method to Detect Localized Constrictions

Pulsed-Power Combined with High Resolution Infrared Imaging

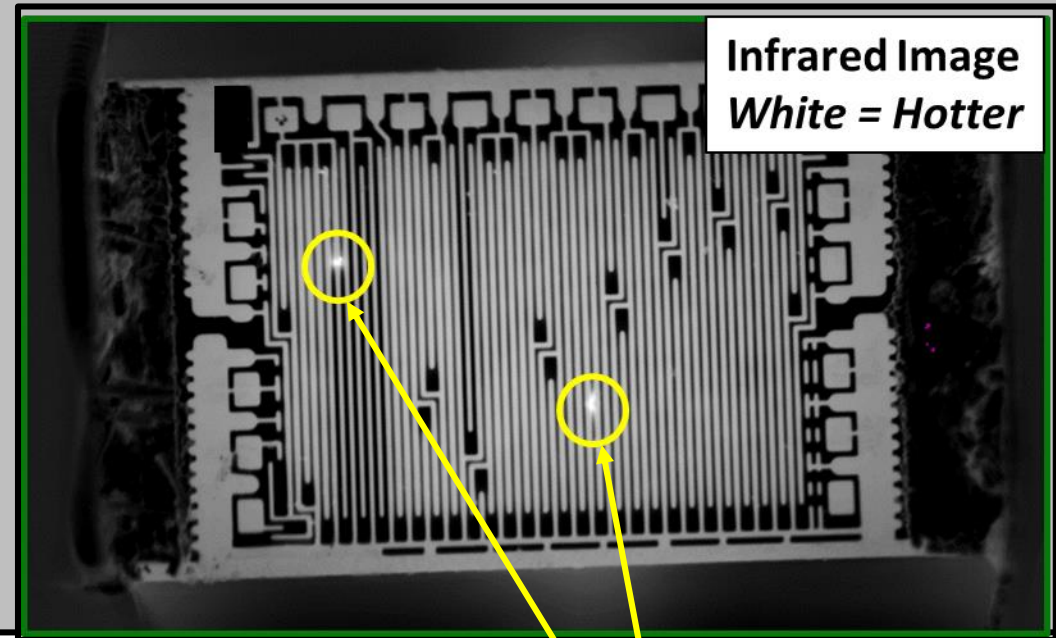


1. Apply pulsed-power to resistor

- 6.25x rated power ← *same as STOL*
- 50 ms, 10% duty cycle
- 1 or more pulses
- These conditions confine heating to the localized constrictions



2. Examine resistor with *high resolution infrared camera* (e.g. FLIR SC8300)



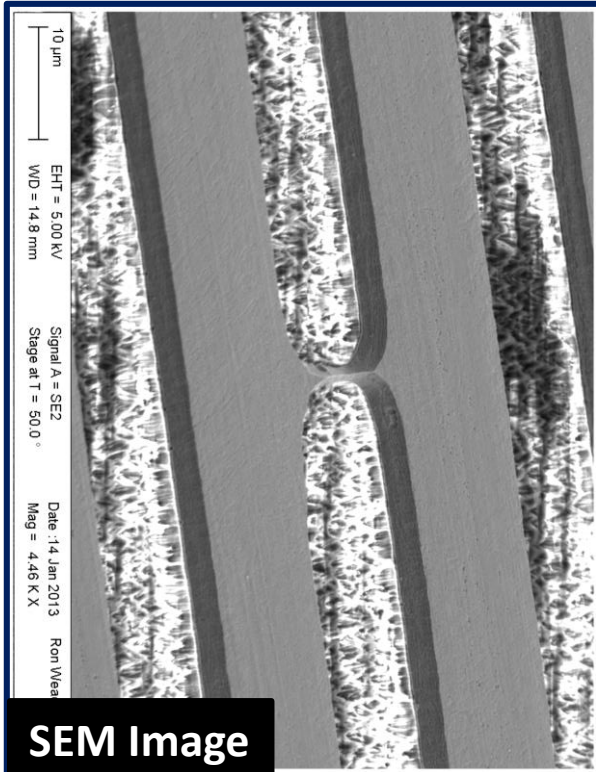
3. Reject resistors with *“hot spots”*

- Hot spots are indicative of constriction defects (e.g., notches, bridges, embedded particles)

Demonstration of New Screening Method

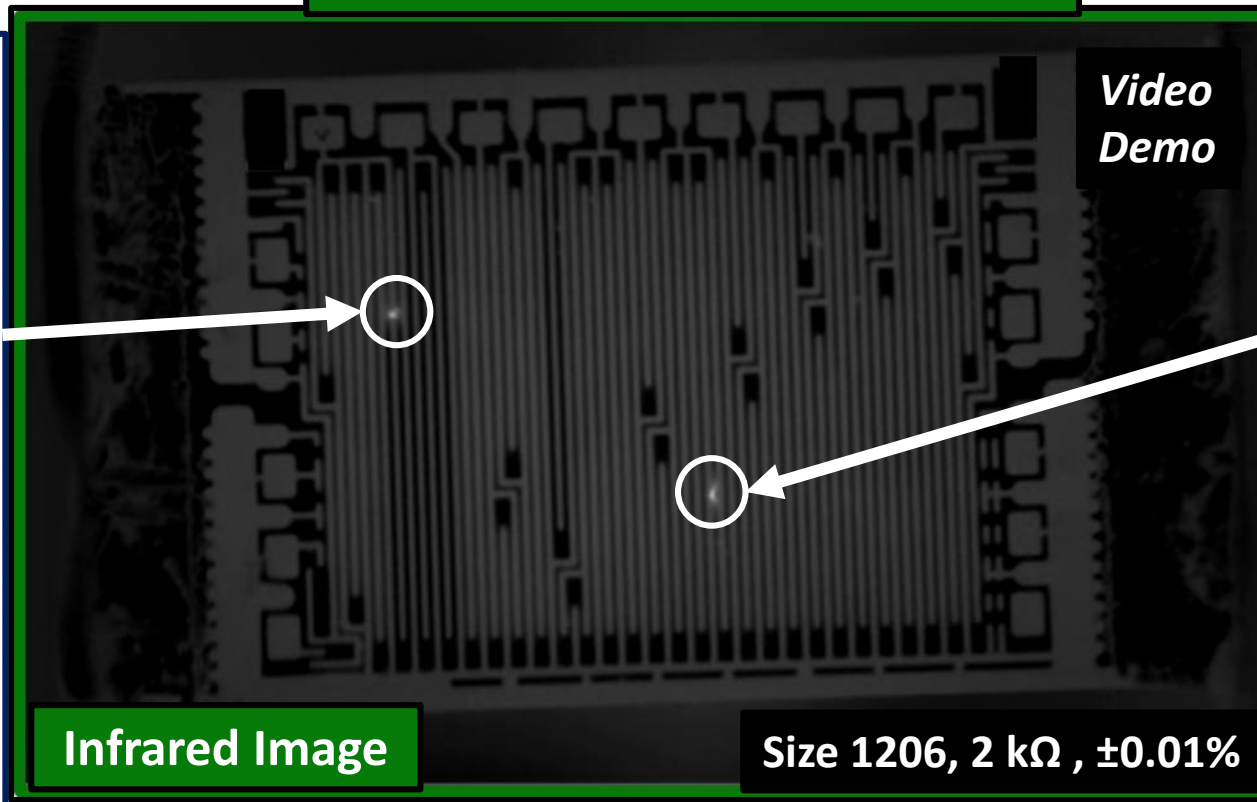
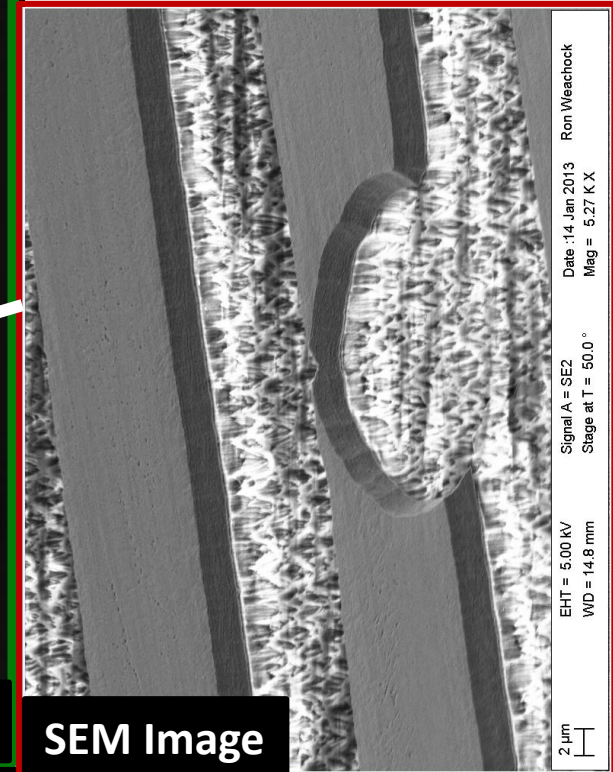
Using DPA Sample with Bridge and Notch Defects

Bridge Defect



Pulsed-Power 6.25x Rated Power
50ms On / 150ms Off

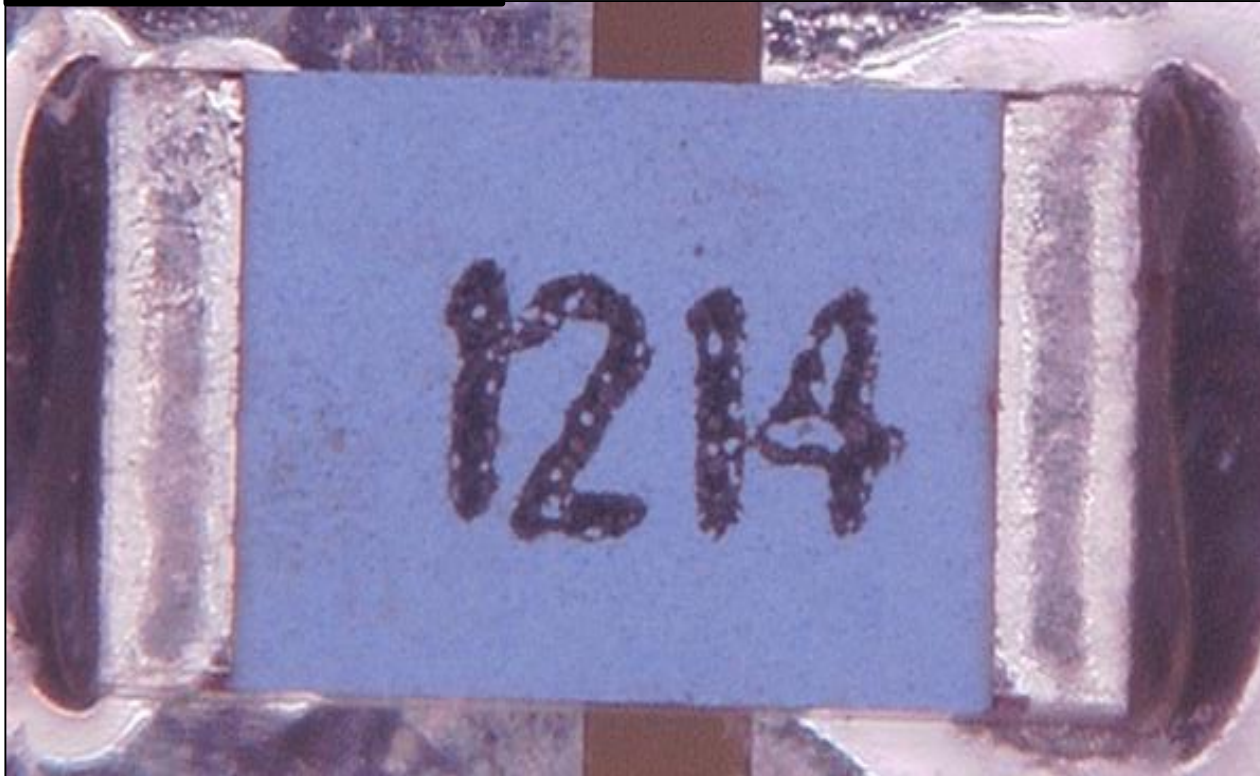
Notch Defect



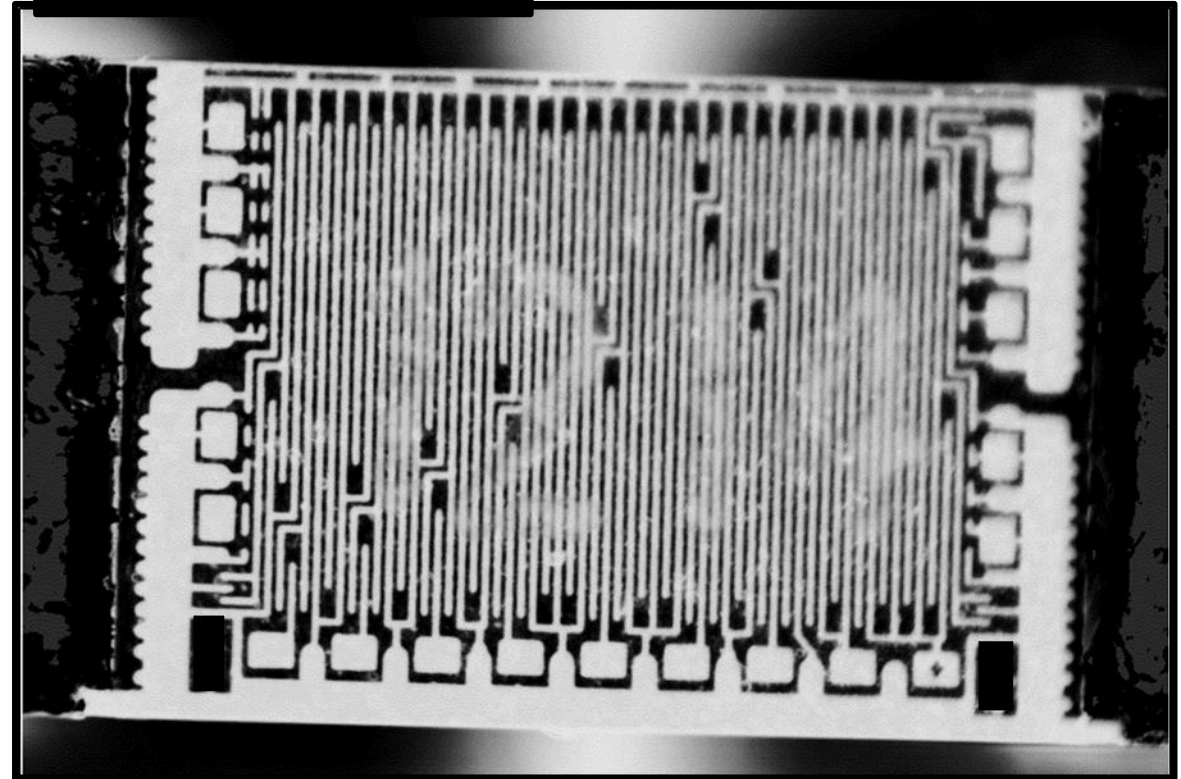
These Protective Coatings are “See Through” for Infrared Wavelengths of $3\mu\text{m}$ to $5\mu\text{m}$
Even With No Power Applied to the Resistor

*Enables Post-Procurement Screening
of SMT Foil Resistors*

Optical Image



Infrared Image





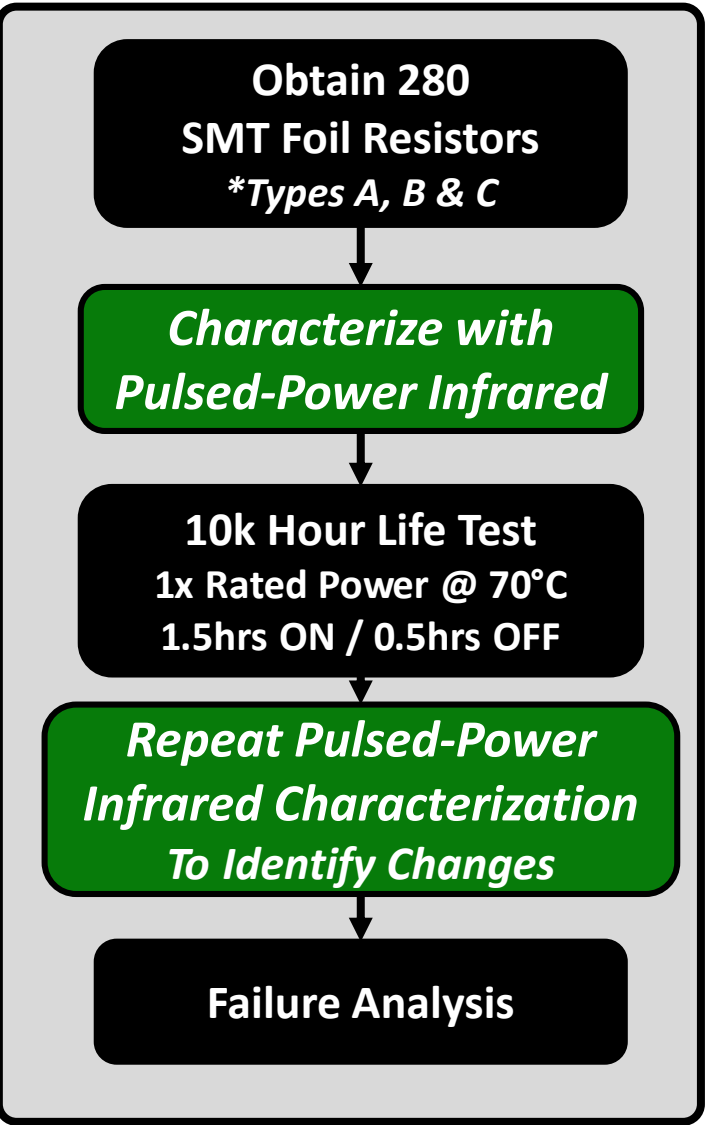
Evaluation of New Screening Method

Foil Resistors Used for Evaluation

Resistor Size (EIA Footprint)	Resistance (Ω) & Tolerance	Power Rating (mW)	Qty	Resistor Pattern Geometry		* Type
				Foil Thickness (μm)	Foil Gridline Width (μm)	
0805	5.1k \pm 0.05%	100	40	2.3	6.6	C
1206	20k \pm 0.05%	150	40	2.5	4.8	A
1206	20k \pm 0.05%	150	40	2.5	4.8	B
1206	23.5k \pm 0.05%	150	40	2.3	4.3	C
1506	36.45k \pm 0.05%	200	40	2.8	4.1	A
1506	36.45k \pm 0.05%	200	40	2.8	4.1	B
2010	50k \pm 0.01%	300	40	2.5	4.8	B

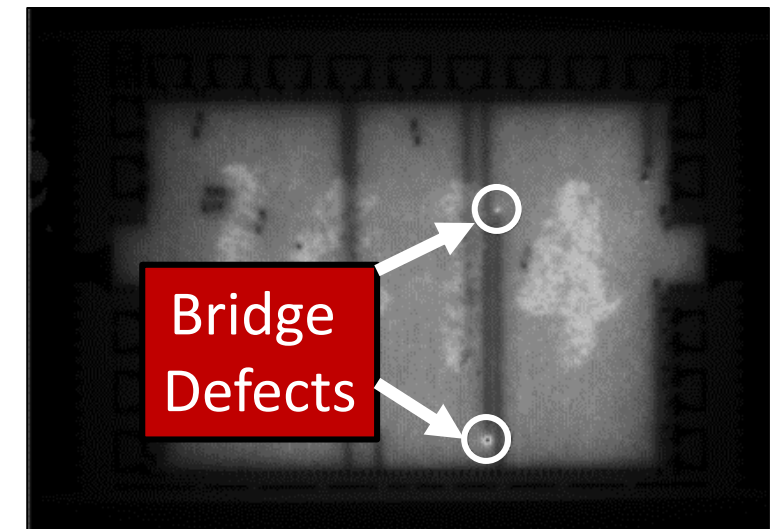
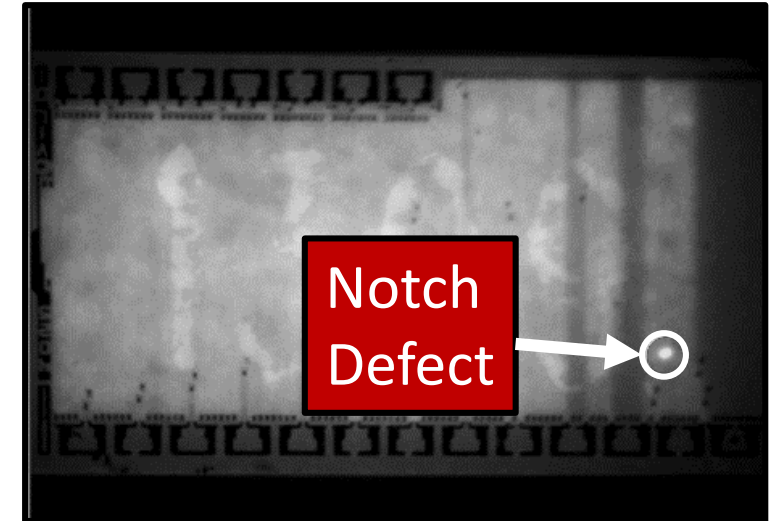
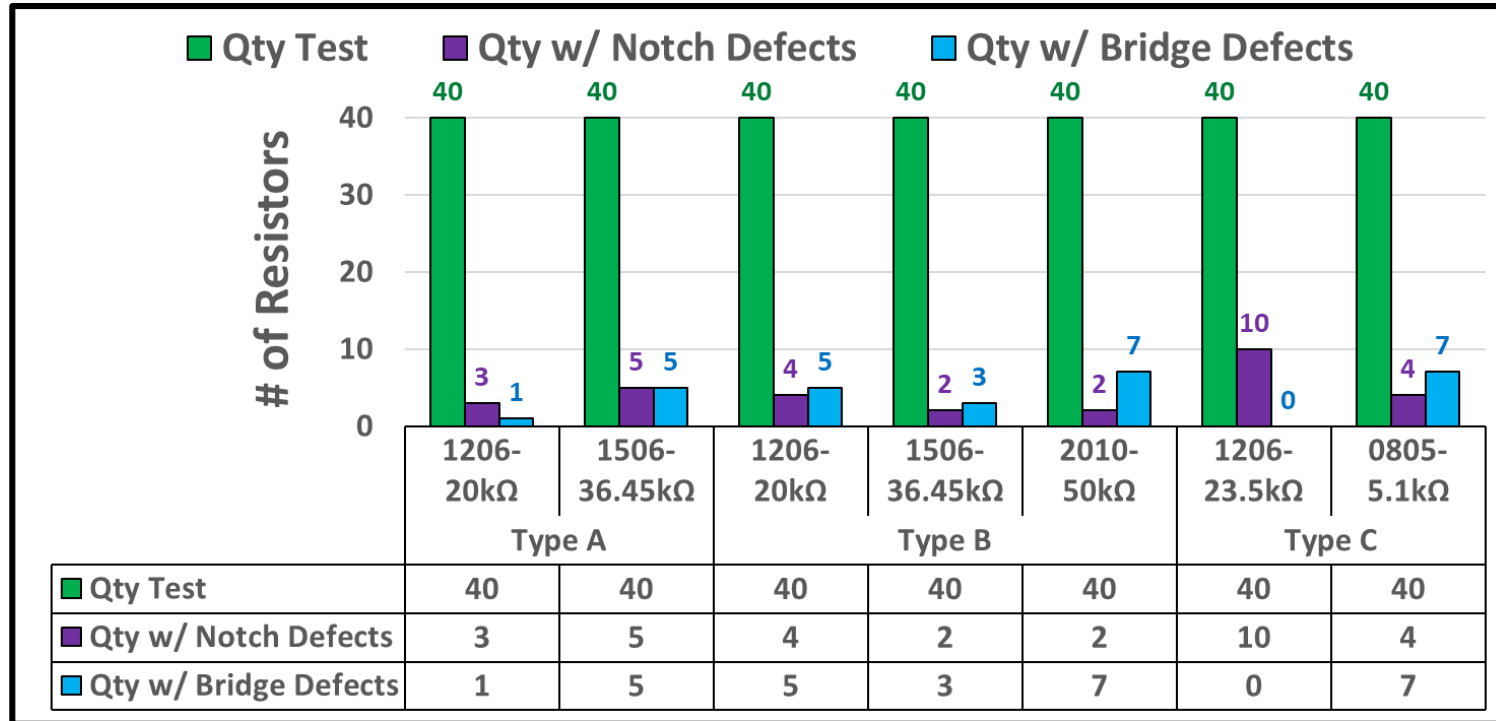
Total 280

*Type	Foil Classification	Pre-Encapsulation Screen	Powered Screening
A	Contains Some "Embedded Particles"	100% Visual Inspection	1x Short Time Overload (STOL)
B	"Particle-Free"	100% Visual Inspection	1x Short Time Overload (STOL)
C	"Particle-Free"	100% Visual Inspection	2x Short Time Overload (STOL)



Results: Pre-Life Test Pulsed-Power Infrared Screening

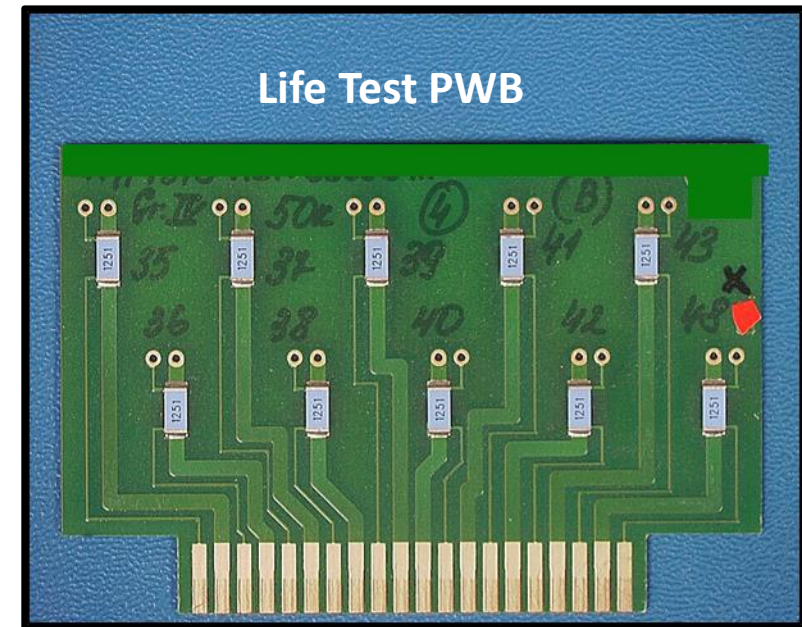
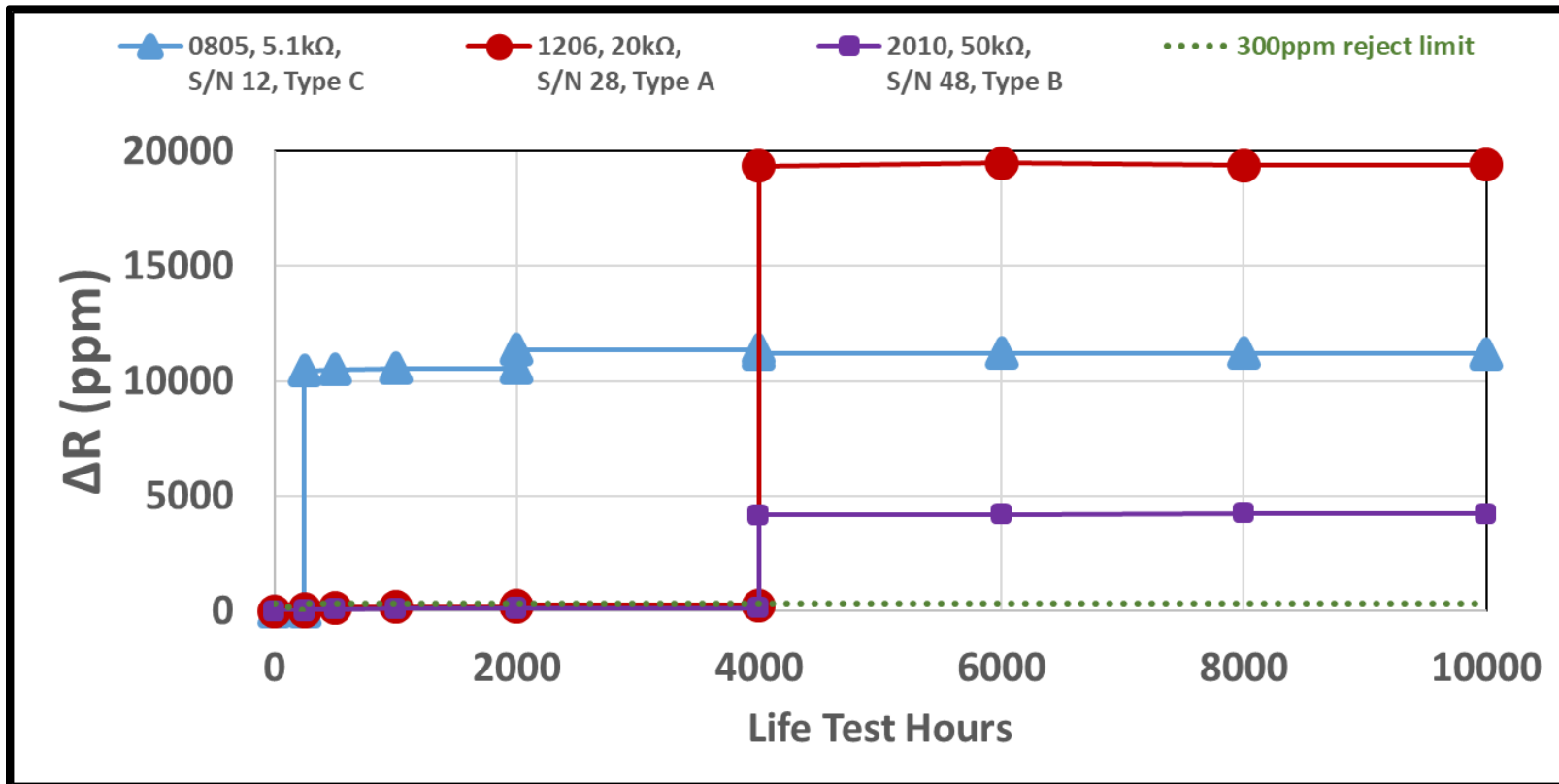
~10% to 25% of Resistors Per Lot Tested Had Constriction Defects



Totals	
	280 Tested
	30 with Notch Defects
	28 with Bridge Defects

Results: 3 Life Test Failures (280 Resistors Tested)

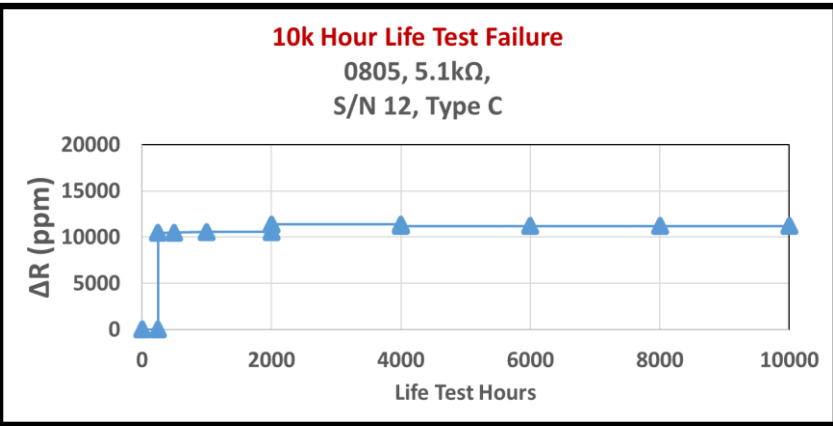
Abrupt Positive Resistance Shift Failure Modes



** S/N 12 exhibits 2 distinct positive shifts during life test*

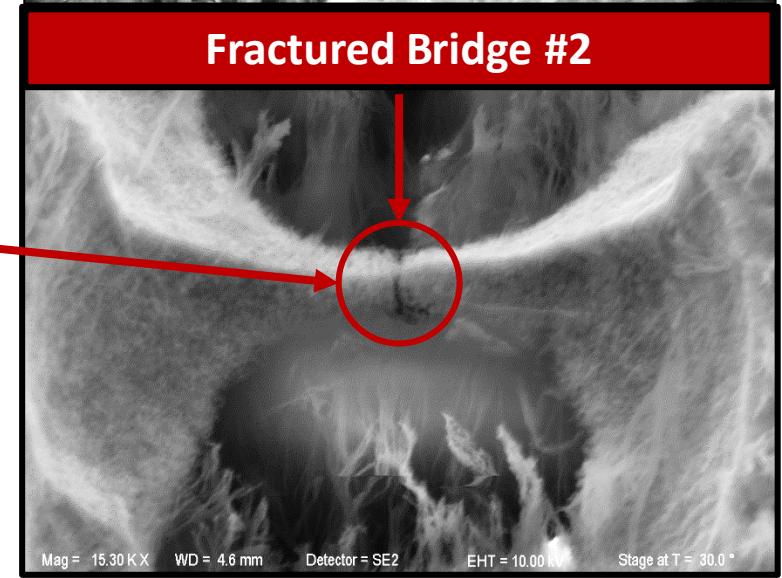
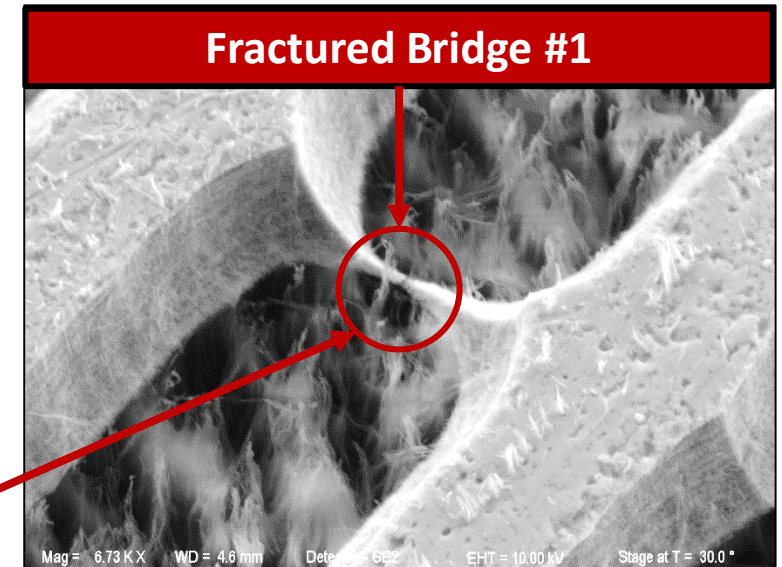
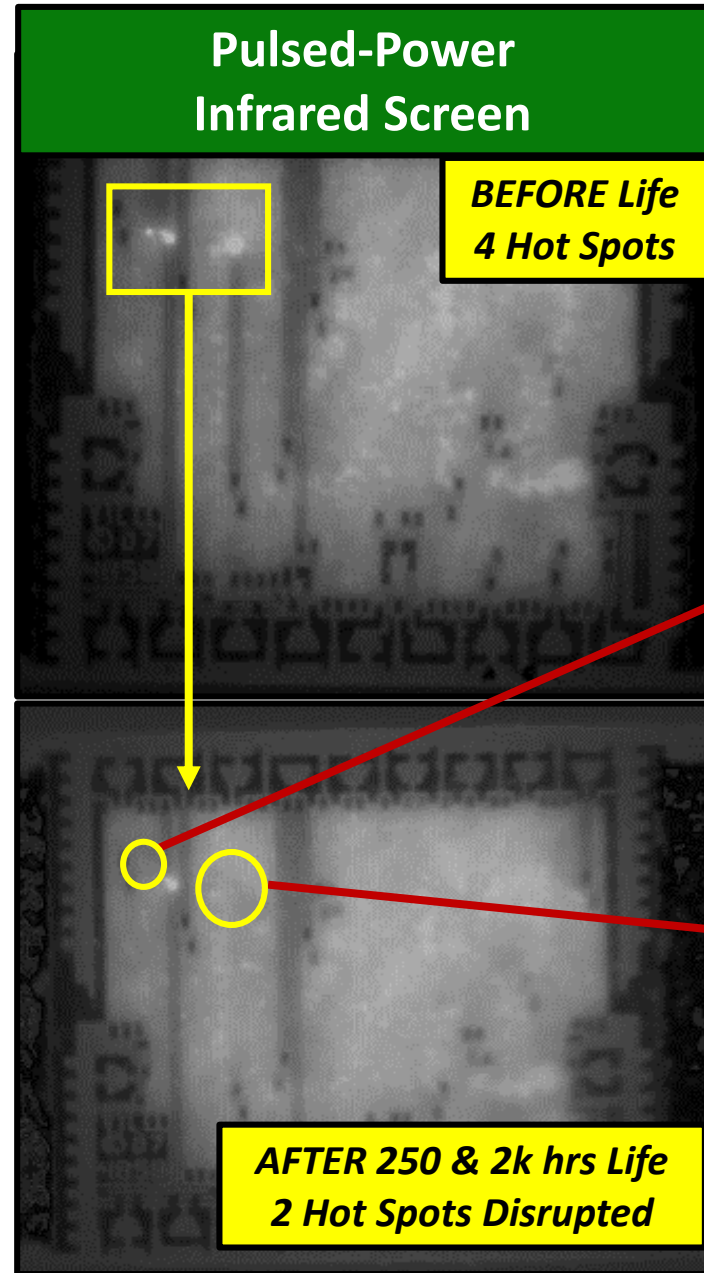
Failure Analysis:

0805, 5.1kΩ, S/N 12, Type "C"



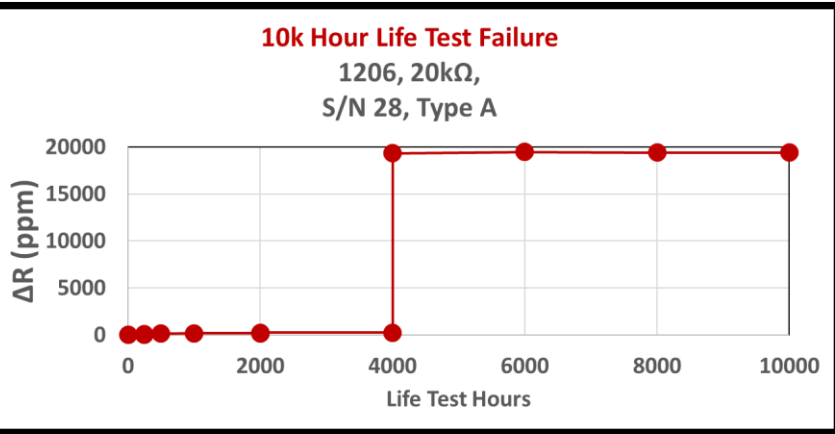
Conclusion:
Two bridge defects fractured during life test causing total ΔR ~11000 ppm

Pulsed-Power Infrared Screen detected both bridge defects as 'hot spots' BEFORE Life Test



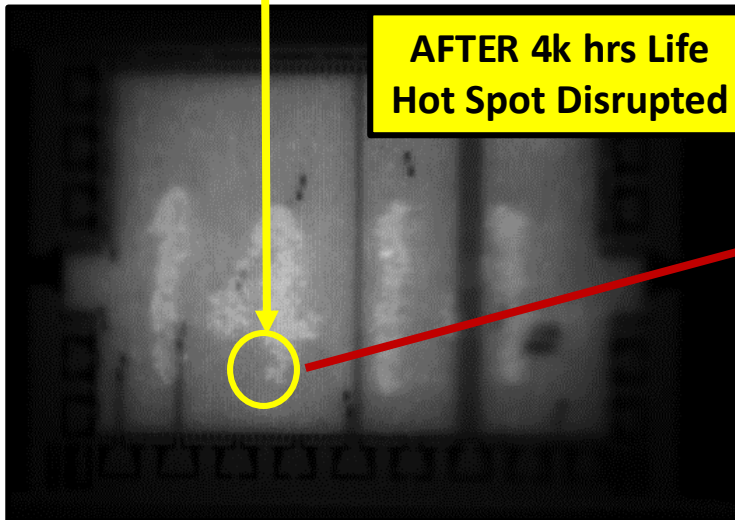
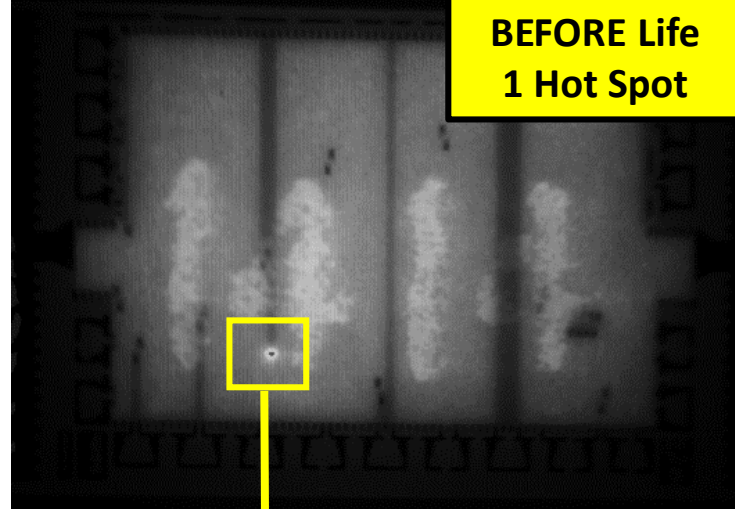
Failure Analysis:

1206, 20kΩ, S/N 28, Type "A"

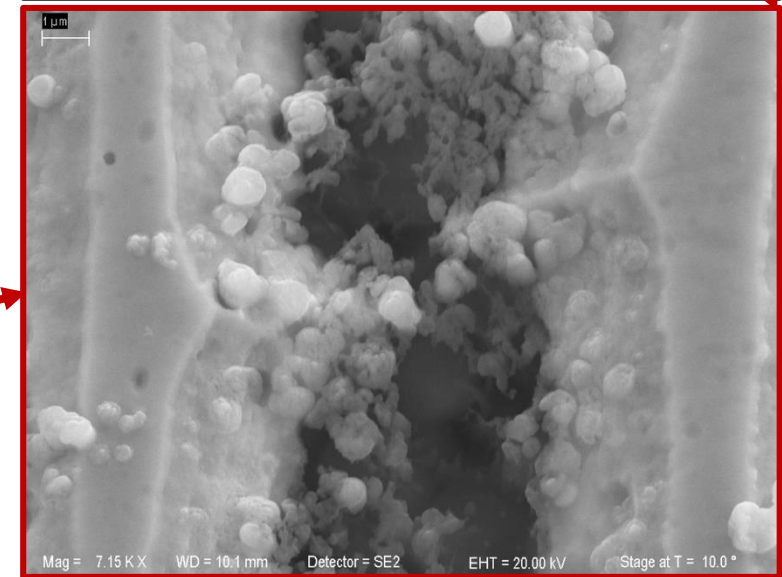
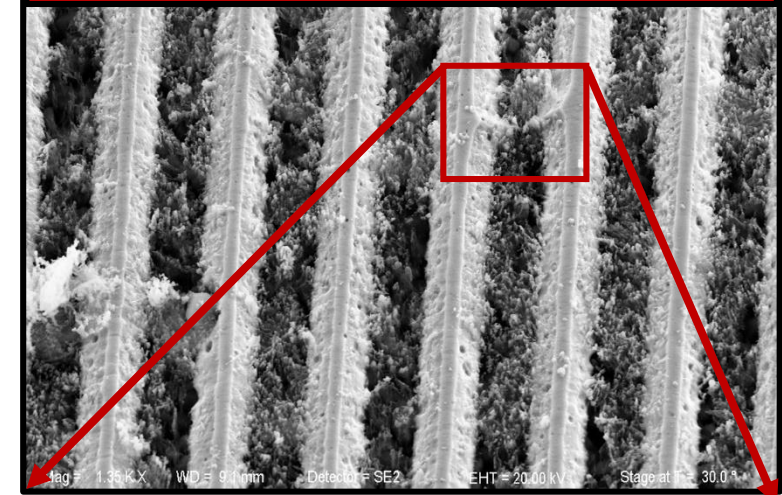


Conclusion:
One bridge defect fractured during life test causing $\Delta R \sim 19400$ ppm
Pulsed-Power Infrared Screen detected this bridge defect as a 'hot spot' BEFORE Life Test

Pulsed-Power Infrared Screen

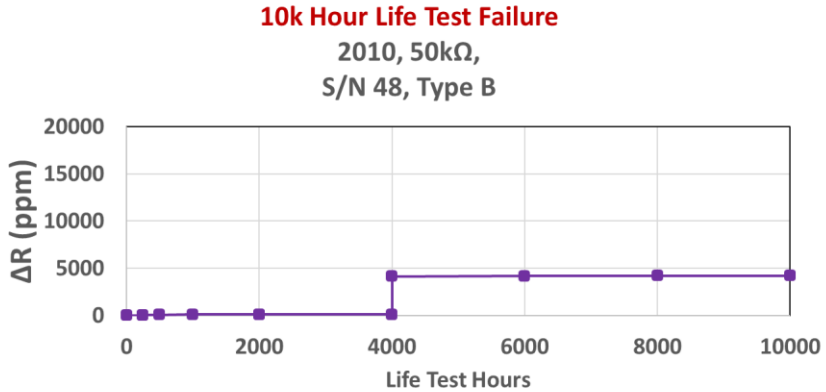


Fractured Bridge



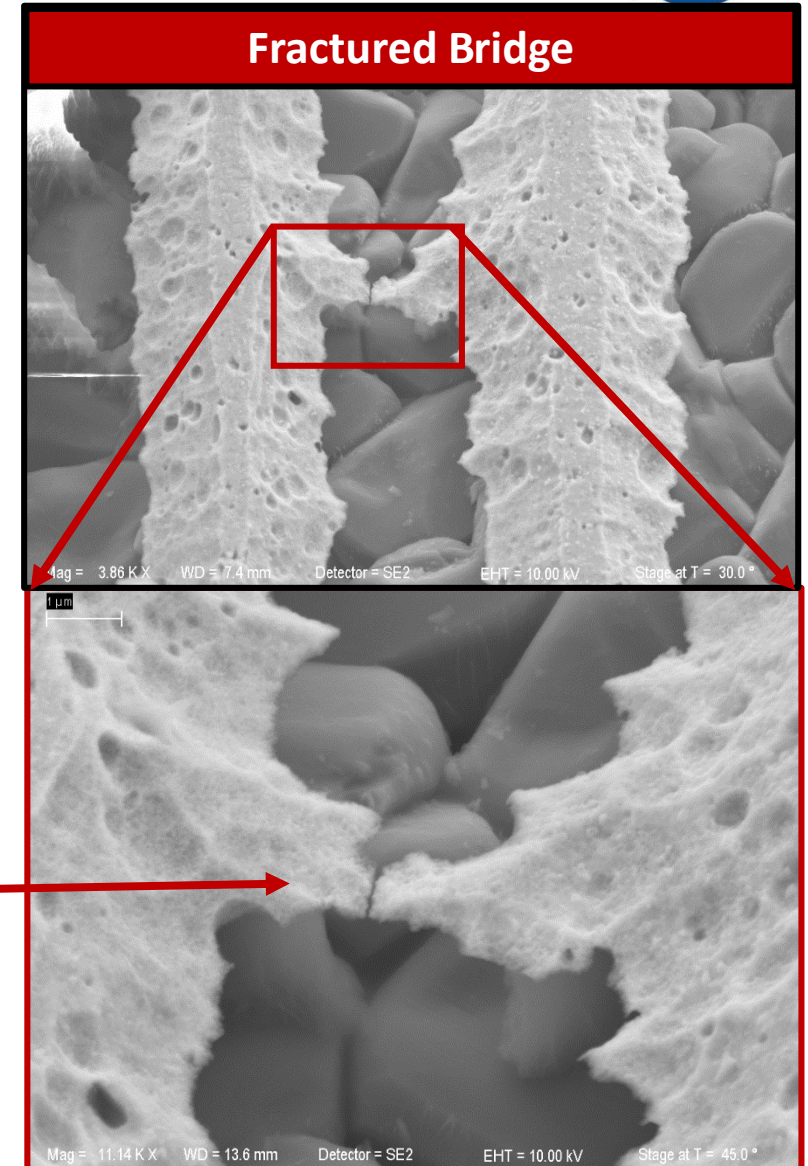
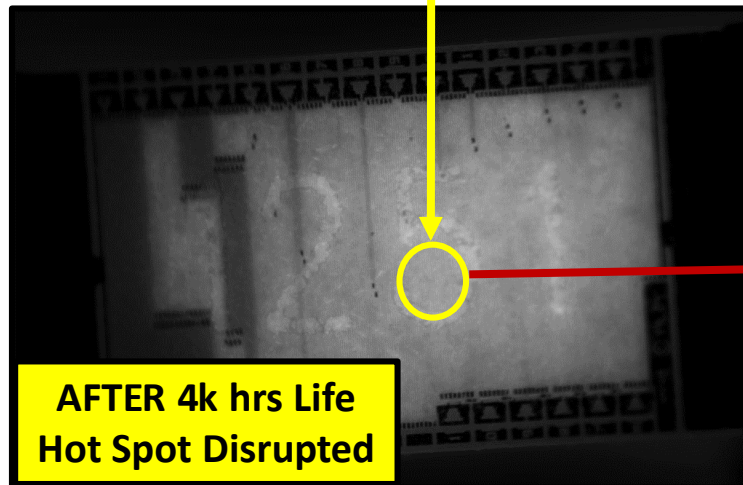
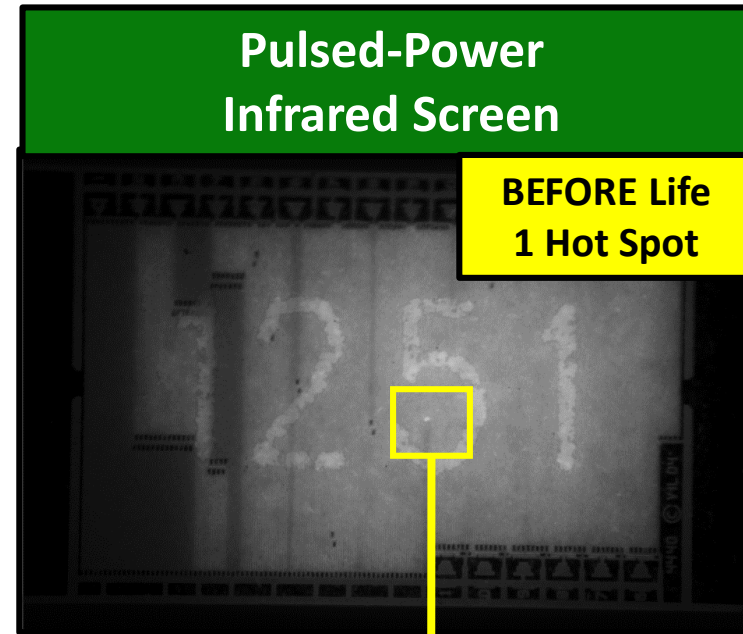
Failure Analysis:

2010, 50kΩ, S/N 48, Type "B"



Conclusion:
One bridge defect fractured during life test causing $\Delta R \sim 4200$ ppm

Pulsed-Power Infrared Screen detected this bridge defect as a 'hot spot' BEFORE Life Test





Conclusions

- 1 Resistor failures (i.e., positive ΔR and open circuit) sometimes occur due to thermomechanically-induced fatigue fracture of localized constriction defects in the resistor pattern (e.g., notches, bridges, embedded particles).**
- 2 Standard screening techniques (e.g., pre-encapsulation visual, STOL, DPA) Do NOT detect all resistors with significant constriction defects in the resistor pattern.**
- 3 New Pulsed-Power Infrared Screening technique has been developed**
 - Detects localized constriction defects as “hot spots” using high resolution infrared thermography*
 - Proven effective via 10k hour life test with failure analyses correlating pre-existing constriction defects to ‘hot spots’ and subsequent fractured constrictions after life test*
 - Suitable for use as an ‘In-Process Manufacturer Screening Inspection’ prior to encapsulation And as a non-destructive ‘Post-Procurement’ screen for SMT foil resistors*

**New Screening Technique Can Take a Super Stable Resistor Technology
and Make it Super Reliable Too**



Acknowledgements

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Office of Safety and Mission Assurance

**Alexandros Bontzos, Chris Greenwell,
Tim Mondy, Nilesh Shah,
Ron Weachock**
NASA Goddard Space Flight Center
Parts Analysis Laboratory

Foil Resistor Samples and Life Testing Services Provided by

Vishay Precision Group (VPG)



Backup Slides

High Resolution Infrared Camera with 4x lens option

FLIR SC8200, SC8300 Series



Parameter	Specification
Detector	InSb
Spectral Range	3 μm to 5 μm
Measurement Temperature Range	-20°C to +350°C
Field of View	~4.6mm x 5.6mm (> 1 million pixels)
Resolution	~ 5 μm per pixel
Focal Working Distance	~25mm
Frame Capture Rate	>100 frames per second (fps)

Comparison of Two Different Infrared Cameras

Inspecting the same resistor with 2 constriction defects while applying power pulses

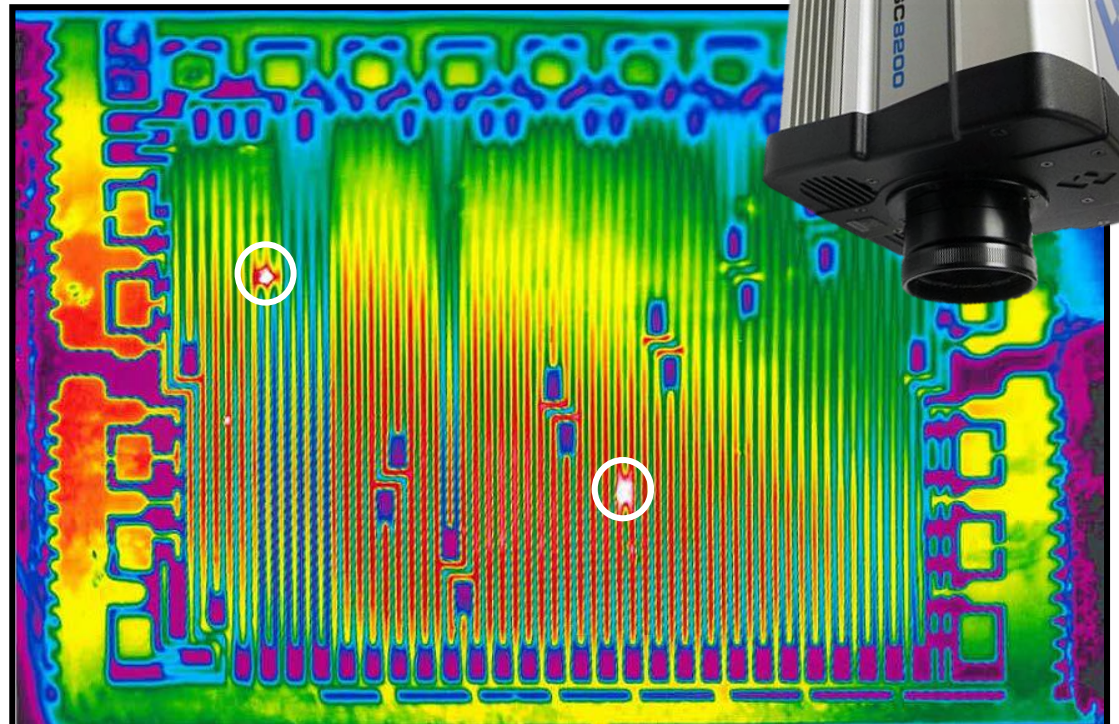
FLIR SC660

~25 μm per pixel



FLIR SC8300HD + 4x Lens

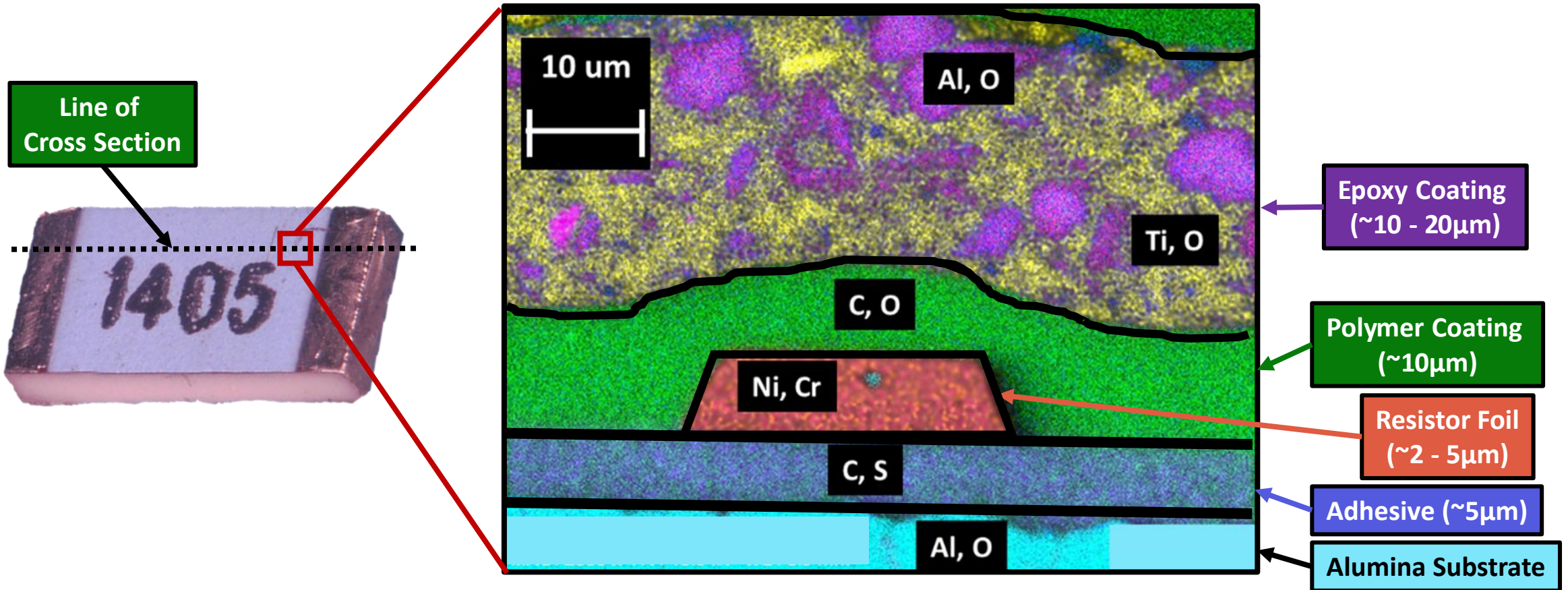
~5 μm per pixel



Basic Construction of a SMT Foil Resistor

Cross Section

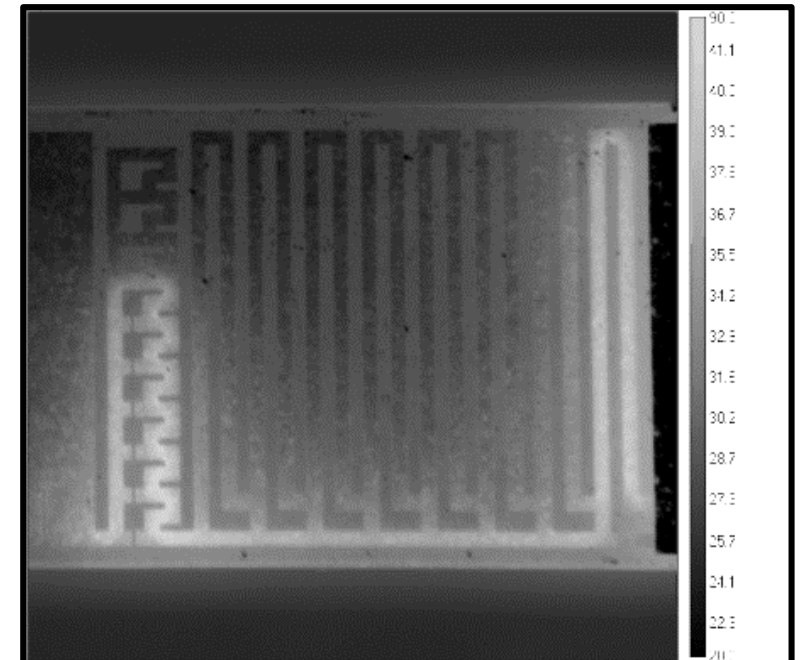
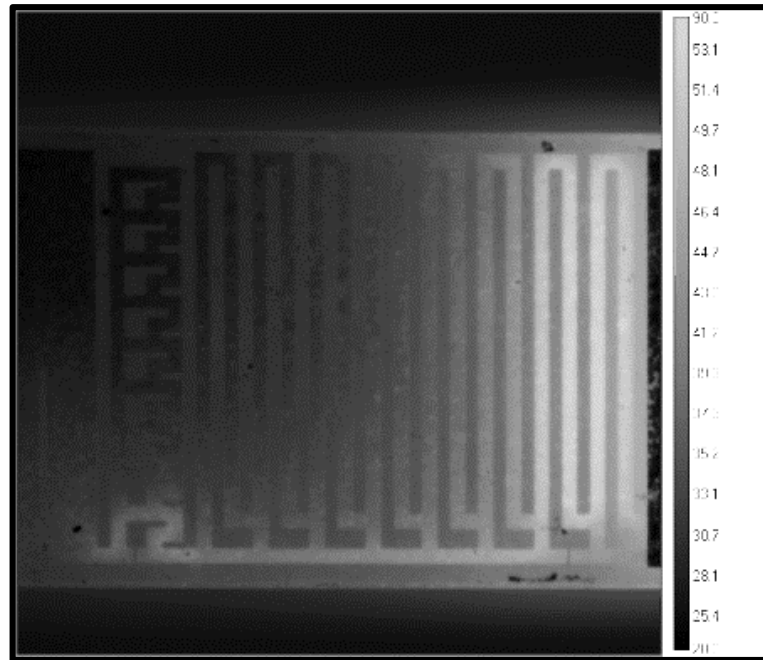
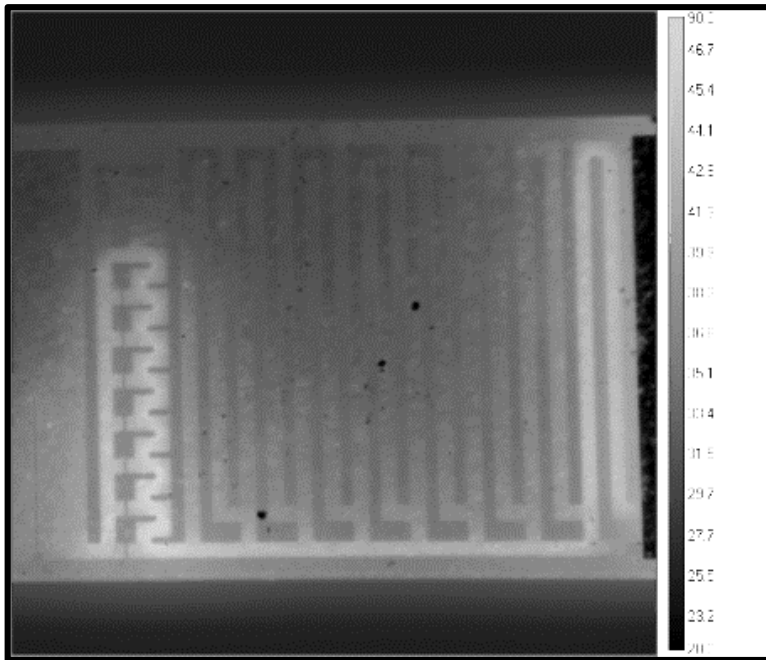
Cross Section



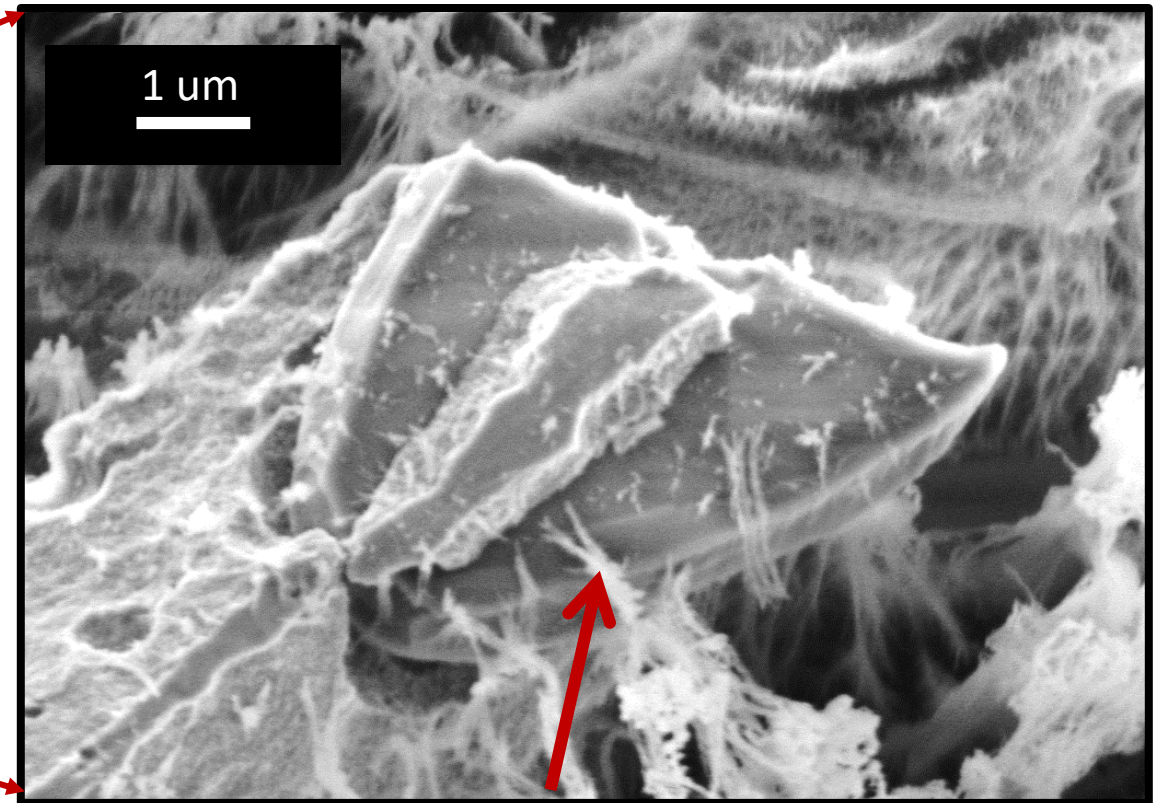
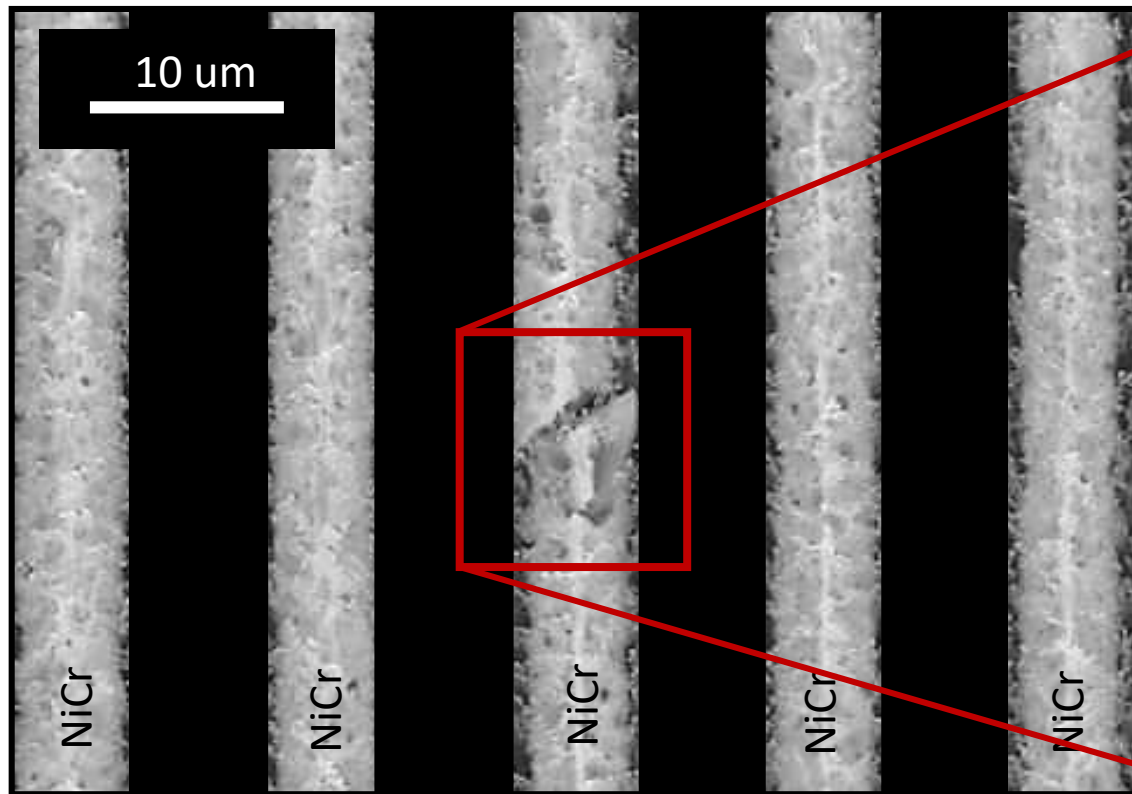
SMT Thin Film Resistors Inspected Using New Pulsed-Power Infrared Screening Method

Applying 6.25x Rated Power for 100 ms pulses; 10% duty cycle

Infrared Inspection Performed Without Removing Resistor Protective Coatings



A Case for an Improved Screening Method: Embedded Al-N Particle in Foil Resistor Size 1206, 30 k Ω



Fractured NiCr Gridline With Embedded Al-N Particle

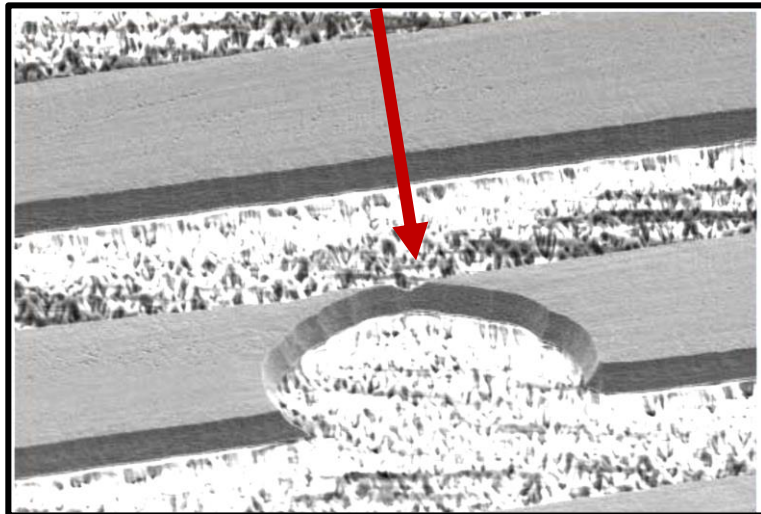
Aluminum Nitride Particle

Traditional Resistor Screening Methods

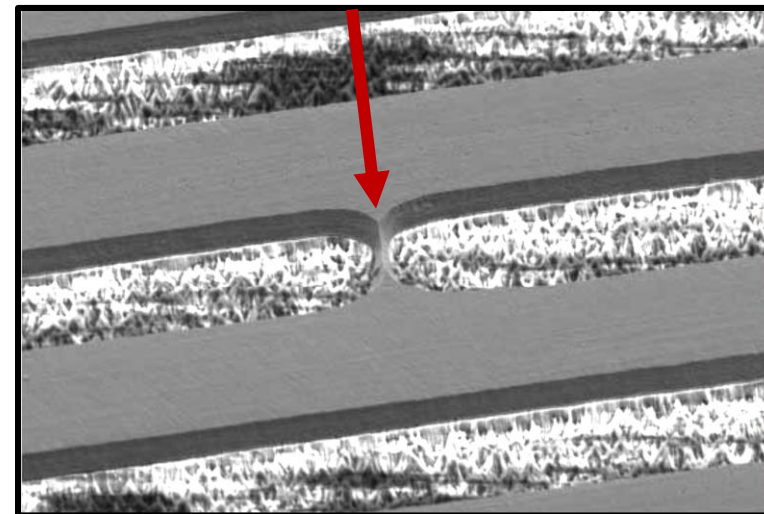
Optical Microscopy

	Thin Film (MIL-PRF-55342)	Foil Resistors
Test Conditions	30x to 60x optical microscopy prior to encapsulation	
Sample Size	100% in-process screen	100% high reliability products only
Rejection Criteria	Voids > 50% nominal line width Bridges < 50% smallest line width	Voids > 75% nominal line width Bridges < 10% smallest line width

Void > 75% in Foil Resistor



Bridge < 10% in Foil Resistor





Traditional Resistor Screening Methods

Short Time Overload (STOL)

	Thin Film (MIL-PRF-55342)	Foil Resistors
Test Conditions	6.25x rated power for 5 seconds	
Sample Size	20 pcs (space level only)	10 pcs (high reliability products)
Rejection Criteria	$\Delta R > 0.1\%$	$\Delta R > 0.02\%$

STOL may sometimes force failure of devices with the most severe pattern constrictions



Traditional Resistor Screening Methods

Power Conditioning

	Thin Film (MIL-PRF-55342)	Foil Resistors
Test Conditions	1.5x rated power for 100 hours at 70°C	
Sample Size	100% (space level only)	100% (high reliability products only)
Rejection Criteria	$\Delta R > 0.2\%$	$\Delta R > 0.03\%$

Power Conditioning may sometimes force failure of devices with the most severe pattern constrictions

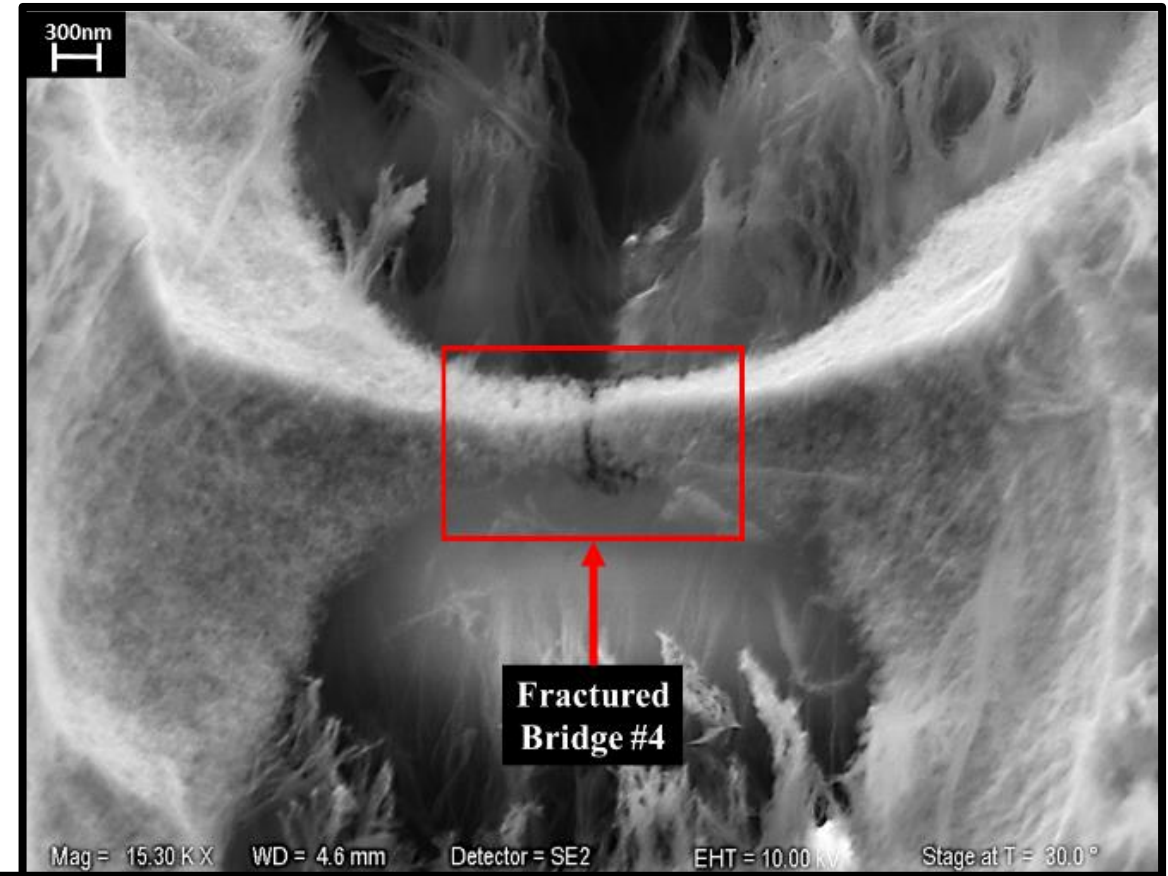
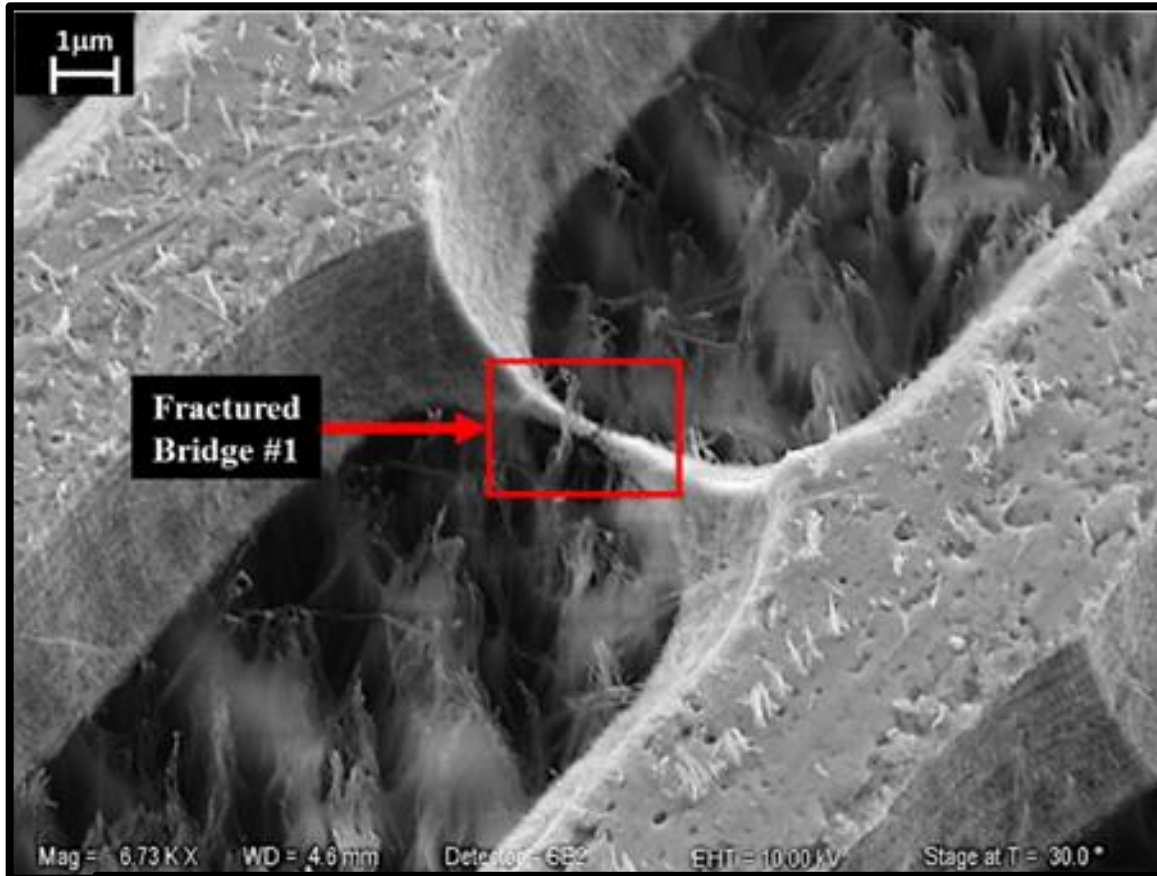
Failure Analysis

0805, 5.1kΩ, S/N 12, Type "C"



Two Positive Resistance Shifts During Life Test

$\Delta R1 = +10440\text{ppm @ 250 hrs}$; $\Delta R2 = +815\text{ppm @ 2000 hrs}$



Conclusion:

This Resistor Exhibited Two Abrupt Positive ΔR Shifts During Life Test.

Both Shifts Were Caused by Thermomechanically-Induced Fatigue Fracture of Two Separate Foil Bridge Defects